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# InSe/Te van der Waals Heterostructure as a High-Efficiency Solar Cell from Computational Screening

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**Abstract:** Designing the electronic structures of the van der Waals (vdW) heterostructures to obtain high-efficiency solar cells showed a fascinating prospect. In this work, we screened the potential of vdW heterostructures for solar cell application by combining the group III–VI MX<sub>A</sub> (M = Al, Ga, In and  $X_A = S$ , Se, Te) and elementary group VI  $X_B$  ( $X_B = Se$ , Te) monolayers based on first-principle calculations. The results highlight that InSe/Te vdW heterostructure presents type-II electronic band structure feature with a band gap of 0.88 eV, where tellurene and InSe monolayer are as absorber and window layer, respectively. Interestingly, tellurene has a 1.14 eV direct band gap to produce the photoexcited electron easily. Furthermore, InSe/Te vdW heterostructure shows remarkably light absorption capacities and distinguished maximum power conversion efficiency (PCE) up to 13.39%. Our present study will inspire researchers to design vdW heterostructures for solar cell application in a purposeful way.

Keywords: van der Waals heterostructure; InSe; tellurene; first-principle calculations; solar cell

## 1. Introduction

Van der Waals (vdW) heterostructures are stacked by two or more two-dimensional (2D) materials with only vdW interaction in their interlayers but no surface dangling bonds [1], which were widely used in vertical field-effect transistors [2], wearable and biocompatible electronics [3], photodetectors [4], photovoltaics [5–7], light-emitting devices (LEDs) [8], and so on. Because vdW force in the interlayer is a long-range weak interaction, the heterostructures can be formed under the existence of large lattice mismatch among the monolayers [9]. Furthermore, vdW heterostructures can combine the excellent properties of the monolayers [10]. Under the interlayer coupling in vdW heterostructures, they can also exhibit novel characteristics that their components do not possess [7,11–13]. Designing type-II vdW heterostructures for solar cells through band-structure engineering by using calculations is an efficient way, such as graphene/GaAs [5], Ti<sub>2</sub>CO<sub>2</sub>/Zr<sub>2</sub>CO<sub>2</sub> [14] and GaSe/GaTe heterostructures [15]. Generally, a vdW heterostructure based high-efficiency solar cell consists of two parts: a absorption layer with a small band gap ( $\sim 1.2-1.6$  eV [16]) and strong light absorption capacity, and a window layer with a large band gap and high transparency for the incident light [17,18]. Besides, the high carrier mobility and the direct band gap of the absorption layer that generates photo-generated electrons are also beneficial for improving the efficiency of solar cells [14,15]. Due to thickness and atomically sharp interfaces, light-generated carriers can be effectively separated in vdW heterostructures. Therefore, the probability of electron-hole recombination is very low, and the efficiency is high [17]. For instance, a 2D WSe<sub>2</sub>-MoS<sub>2</sub> lateral p-n heterojunction with



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**Copyright:** © 2021 by the authors. Licensee MDPI, Basel, Switzerland. This article is an open access article distributed under the terms and conditions of the Creative Commons Attribution (CC BY) license (https:// creativecommons.org/licenses/by/ 4.0/). a power conversion efficiency (PCE) of 2.56% under AM1.5G illumination was designed, which can help develop the next-generation photovoltaics [19]. Hence, finding vdW heterostructures with suitable band gaps and light absorption abilities to obtain high solar energy efficiency is of great interest and importance.

On the other hand, the group III–VI compounds represented by InSe are a kind of layered hexagonal lattice semiconductor [20–22]. The layers of them are connected by vdW force without dangling bonds. Excitingly, 2D InSe was successfully prepared experimentally, which exhibits high electron mobility, quantum Hall effect, and anomalous optical response [23]. Moreover, the 2D InSe related vdW heterostructures combined with another layers such as graphene [24], black phosphorus [25],  $C_3N_4$  [26], SiGe [7], or III–VI monolayers [15,27] attracted remarkable attention for high-performance electronic and optoelectronic devices. Recently, the 1T-MoS<sub>2</sub>-like phase *T*-Se and  $\alpha$ -Te were successfully obtained in the laboratory [28,29]. The III–VI monolayers and *T*-Se,  $\alpha$ -Te are all P63/mmc lattice semiconductors with great optical properties and high carrier mobility [15,30]. Theoretically, the selenene and tellurene are evaluated as indirect band gaps of 1.16 and 1.11 eV [30], respectively, which may be converted to direct band gaps after the formation of vdW heterostructures [31]. Therefore, it is highly desirable to build group III–VI/selenene and III–VI/tellurene vdW heterostructures, which are good candidates for the absorption layers for solar cell application.

In this work, we established the  $MX_A/X_B$  vdW heterostructures by combining  $MX_A$  (M = Al, Ga, In and  $X_A = S$ , Se, Te) and  $X_B$  ( $X_B = Se$ , Te) monolayers. Based on firstprinciples calculations, we unraveled the electronic structure of each monolayer and heterostructure. Then, according to the energy band requirement of solar cells, InSe/Te vdW heterostructure was screened out for the further study. Our results demonstrated that InSe/Te vdW heterostructure shows type-II electronic band structure feature whose tellurene as absorber layer exhibits 1.14 eV direct HSE band gap, exhibiting distinguished light absorption capacities. Moreover, the corresponding maximum PCE can reach up to 13.39%, which indicates that InSe/Te vdW heterostructure has great potential for highefficiency solar cells.

### 2. Materials and Methods

The first-principles calculations were based on density functional theory (DFT) using the Vienna ab initio simulation package (VASP) [32–35] in conjunction with the projector augmented wave (PAW) pseudopotentials [32,36]. The calculation models and results were dealt with the ALKEMIE platform [37]. The generalized gradient approximation (GGA) [38] of Perdew–Burke–Ernzerhof (PBE) [39] pseudopotentials were selected to descried the exchange correlation interactions between electrons. Our work conducted by using van der Waals (vdW) interaction to form a heterostructure with two monolayers. Since the weak interaction is difficult to be evaluated by traditional exchange and correlation potentials [40], the optB86b-vdW functional [41] was used to include the weak interaction in all the calculations. For the lattice optimization, the cutoff energy and the convergence criteria for energy were set to 500 eV and 10<sup>-5</sup> eV·atom<sup>-1</sup>, respectively. We maintained a sufficiently large vacuum space (~20 Å vacuum for each layer) in the z-direction, and a proper distance  $(\sim 3 \text{ Å})$  between the two layers in order to ensure that there was only vdW interaction between the different layers and no significant interaction among the repeating units in the vertical direction. In geometric optimizations and static self-consistent calculations, k-sampling was performed using  $9 \times 9 \times 1$  points by the Monkhorst–Pack [42] mesh. The Heyd–Scuseria–Ernzerhof (HSE06) [41] hybrid functional was used to evaluate the electronic band gaps.

## 3. Results and Discussion

#### 3.1. Geometry and Stability

The MX<sub>A</sub> (M = Al, Ga, In and  $X_A = S$ , Se, Te) and  $X_B$  (X<sub>B</sub> = Se, Te) monolayers, where the positions of the elements in the periodic table are shown in Figure 1a, are crystallized

in the space group of *P63/mmc* with a honeycomb hexagonal structure [30,43]. Table S1 lists the optimized lattice constant, bond length and band gaps for the monolayers, where the results are in good agreement with the previous reports [44,45]. The lattice constants of most of the  $MX_A$  and  $X_B$  monolayers are close to each other; for instance, the lattice differences between AlSe monolayer and selenene, InSe monolayer and tellurene, are 0.062 and 0.144 Å, respectively. The corresponding mismatches are 1.6% and 3.4%, respectively. The well matched crystalline nature is beneficial for the assembly of van der Waals (vdW) heterostructures, as illustrated in Figure 1b,c.



**Figure 1.** (a) Position in periodic table of elements for  $MX_A/X_B$  (M = Al, Ga, In,  $X_A = S$ , Se, Te and  $X_B = Se$ , Te) heterostructures. (b) top- and (c) side-views of optimized structure of  $MX_A/X_B$  heterostructures.

We established the  $MX_A/X_B$  vdW heterostructures by placing the  $X_B$  monolayers on the top of  $MX_A$  monolayers. There are six possible stacking configurations of the heterostructures [46], named configurations (a) to (f) in Figure 2. In configuration (a),  $X_A$ atom of the  $MX_A$  monolayer is placed below the bottom  $X_B$  atom. While in configurations (b) or (c),  $X_A$  atom is located in the bottom of the middle or upper  $X_B$  atom. At the same time, we can also regard configurations (b) and (c) as the shifting of the  $X_B$  monolayer in configuration (a) along the [110] direction of 1/3 and 2/3 *a*, respectively. Besides, the configurations (d), (e), and (f) can be obtained by flip the  $X_B$  monolayer of (a), (b), and (c) types around the horizontal plane with an angle of 180°. After structural optimizations for a total of 288 structures of all the  $MX_A/X_B$  heterostructures, the energy differences between different configurations, the interlayer distances, lattice constants, and bond lengths are listed in Tables S2–S4. The energy difference  $\Delta E_i$  refers to the difference between the corresponding configuration and the most stable configuration, which can be defined as follows [47]:

$$\Delta E_{\rm i} = E_{\rm i} - E_0 \tag{1}$$

where  $E_i$  is the total energy of each configuration, and  $E_0$  is the total energy of the most stable configuration. The most stable configuration, which has zero  $\Delta E_i$ , is presented in configurations (b) and (d). Moreover, the calculated total energy of various configurations relies on the interlayer distances and lattice constants [48]. Therefore, configurations (b) and (d) show a lower interlayer distance. Moreover, Figure 2 shows that the atom in the bottom of X<sub>B</sub> monolayer is not aligned with any atom in MX<sub>A</sub> monolayer.

To evaluate the thermodynamic stability and interlayer interaction, we calculated the formation energy  $E_f$  and binding energy  $E_b$  for the heterostructures according to the following equations:

$$E_{\rm f} = E_{\rm total} - E_{\rm MX_A} - E_{\rm X_B} \tag{2}$$

$$E_{\rm b} = -\frac{E_{\rm total} - E_{\rm MX_A + X_B}}{A} \tag{3}$$

where  $E_{\text{total}}$  is the total energy of the MX<sub>A</sub>/X<sub>B</sub> heterostructures.  $E_{\text{MX}_{\text{A}}}$  and  $E_{\text{X}_{\text{B}}}$  represent the total energy of pristine MX<sub>A</sub> and X<sub>B</sub> monolayers, respectively. In addition,  $E_{\text{MX}_{\text{A}}+X_{\text{B}}}$  is the sum of the total energy of the mutually independent MX<sub>A</sub> and X<sub>B</sub> monolayers fixed in the corresponding heterostructure lattices, and *A* is the interface area. Table 1 lists the formation and binding energies and other related parameters of the most stable configuration of the MX<sub>A</sub>/X<sub>B</sub> heterostructures. In addition, most of heterostructures have the negative value of

formation energy, which indicates that the reaction of combining monolayers to form these heterostructures is energetically favorable [49]. For example, those of AlTe/Te, GaTe/Te and InSe/Te heterostructures are -280.3, -300.8 and -278.7 meV, respectively. On the other hand, all the heterostructures have the binding energy around  $\sim 20 \text{ meV/}\text{Å}^2$ , which is the sign of vdW interaction between two monolayers [50].



**Figure 2.** Top (**a**) and side (**b**) views of  $MX_A/X_B$  heterostructures with various configurations. Red, brown, blue balls indicate the M,  $X_A$ ,  $X_B$  atoms, respectively.

**Table 1.** Most stable configurations, lattice constants *a* (Å), formation energies  $E_f$  (meV), binding energies  $E_b$  (meV/Å<sup>2</sup>), PBE, and HSE band gaps  $E_g^{PBE}$  (eV) and  $E_g^{HSE}$  (eV), and band edge alignment types for MX<sub>A</sub>/X<sub>B</sub> vdW heterostructures.

System	Configuration	a	Ef	E <sub>b</sub>	$E_{g}^{PBE}$	$E_{g}^{HSE}$	Туре
AlS-Se	d	3.627	-174.0	20.7	1.00	1.35	Ι
AlS-Te	d	3.822	492.3	20.4	0.15	0.55	Ι
AlSe-Se	d	3.744	-246.9	20.9	0.76	1.20	Ι
AlSe-Te	d	3.935	58.5	20.4	0.52	0.90	Ι
AlTe-Se	b	3.965	-67.9	24.1	0.43	0.75	V
AlTe-Te	d	4.129	-280.3	20.5	0.83	1.18	Ι
GaS-Se	d	3.660	-213.7	21.2	0.76	1.21	Ι
GaS-Te	d	3.863	328.0	22.4	0.00	0.26	II
GaSe-Se	d	3.764	-250.0	21.5	0.60	1.12	Ι
GaSe-Te	d	3.963	-24.3	21.8	0.20	0.64	II
GaTe-Se	b	3.980	-74.8	25.6	0.36	0.67	II
GaTe-Te	d	4.141	-300.8	21.4	0.58	1.09	Ι
InS-Se	b	3.829	-206.7	21.4	0.60	0.99	Ι
InS-Te	d	4.024	-164.8	21.7	0.16	0.50	II
InSe-Se	b	3.921	-107.9	22.7	0.44	0.99	Ι
InSe-Te	d	4.112	-278.7	21.5	0.39	0.88	II
InTe-Se	b	4.124	178.0	29.0	0.20	0.49	V
InTe-Te	b	4.290	-309.5	21.7	0.44	0.89	V

#### 3.2. Electronic Properties

A high-efficiency heterostructure solar cell requires the type-II band structure feature, and the absorption layer has a lower band edge than the window layer, preferably with a direct band gap of 1.2–1.4 eV [16,17]. Figure S1 illustrates the projected band structures and band edge alignments of  $MX_A$  and  $X_B$  monolayers by using HSE06 hybrid functional, while Table S1 lists their corresponding PBE and HSE band gaps. For instance, the conduction band minima (CBM) and band gap for InSe monolayer are -4.46 and 2.32 eV, and CBM and band gap for tellurene are -4.49 and 1.09 eV, respectively. In addition, the CBM of tellurene located in  $\Gamma$  point is only 0.07 eV higher than the energy of the point where VBM located in valance band.

Figure 3 illustrates the HSE band structures of all the  $MX_A/X_B$  heterostructures. GaS/Te, GaSe/Te, InS/Te and InSe/Te are all type-II heterostructures with tellurene as the absorption layer. The black short lines mark the corresponding positions of the CBM and VBM of tellurene. In the band structures of GaSe/Te, InS/Te, and InSe/Te, there are two lines in valence bands because their energy levels are similar. The overlap band structures of mutually independent monolayers fixed in InSe/Te heterostructure and the projected HSE band structure of InSe/Te vdW heterostructure are illustrated in Figure 4. Tellurene exhibits the direct band gap of 1.14 eV. And there is 0.36 eV conduction band offset (CBO) between InSe monolayer and tellurene to separate charges [51]. Therefore, InSe/Te vdW heterostructure has the suitable band structure for solar cells.



**Figure 3.** Projected band structures of  $MX_A/X_B$  heterostructures by HSE hybrid functional method. Red and blue circles represent projected weight of  $MX_A$  and  $X_B$  monolayers, respectively.



**Figure 4.** (**a**) Overlap band structures of mutually independent monolayers fixed in InSe/Te heterostructure and (**b**) projected band structure of InSe/Te heterostructure via HSE06 hybrid functional method.

#### 3.3. Solar Cell Applications

To further evaluate the light absorption capacity and reflectivity of InSe/Te vdW heterostructure, we calculated the absorption coefficient and reflectivity by the following formula [52]:

$$n(\lambda) = \frac{1}{\sqrt{2}} \sqrt{\varepsilon_1(\lambda) + \sqrt{\varepsilon_1^2(\lambda) + \varepsilon_2^2(\lambda)}}$$
(4)

$$\kappa(\lambda) = \frac{1}{\sqrt{2}}\sqrt{-\varepsilon_1(\lambda) + \sqrt{\varepsilon_1^2(\lambda) + \varepsilon_2^2(\lambda)}}$$
(5)

$$\alpha(\lambda) = \frac{2\pi\varepsilon_2}{\lambda} \tag{6}$$

$$R(\lambda) = \frac{(n-1)^2 + \kappa^2}{(n+1)^2 + \kappa^2}$$
(7)

where  $\lambda$  is the photon wavelength,  $\varepsilon_1$  and  $\varepsilon_2$  are the real and imaginary parts of the dielectric function, respectively, and  $n(\lambda)$ ,  $\kappa(\lambda)$  are the refractive index and the extinction coefficient, respectively.  $\alpha(\lambda)$  and  $R(\lambda)$  are the absorption coefficient and reflectivity, respectively.

The absorption coefficients and reflectivity curves of InSe/Te heterostructure, InSe monolayer and tellurene are shown in Figure 5. Herein, tellurene as the absorption layer exhibits the high absorption coefficient about  $10^5$  to  $10^6$  cm<sup>-1</sup> in the visible light, which can be comparable with that of bulk WS<sub>2</sub> and WSe<sub>2</sub> used in efficient single junction solar cell [53]. The InSe monolayer as the window layer is required high transparency for the incident light, which means low absorption coefficient and reflectivity [17,54]. The InSe monolayer has an absorption coefficient about 0.13 to 0.34 in the range of 0 to 4 eV photon energy. This result can be compared with that of the Janus WSeTe monolayer used as buffer layer [54].



Figure 5. (a) Calculated optical absorption coefficients as well as (b) the reflectivity of InSe/Te heterostructure, InSe monolayer, and tellurene. Curve in bottom indicates reference solar spectral irradiance, and colorful background represents visible light area [55].

To more intuitively evaluate the solar energy conversion ability of InSe/Te vdW heterostructure, we evaluated the power conversion efficiency (PCE)  $\eta$  in the limit of 100% external quantum efficiency (EQE) by the following equation [6,51]:

$$\eta = \frac{0.65(E_{\rm g} - \Delta E_{\rm c} - 0.3) \int_{E_{\rm g}}^{\infty} \frac{P(\hbar\omega)}{\hbar\omega} d(\hbar\omega)}{\int_{0}^{\infty} P(\hbar\omega) d(\hbar\omega)}$$
(8)

where 0.65 is the band-fill factor,  $P(\hbar\omega)$  is the AM1.5 solar energy flux at the value of  $\hbar\omega$  for photon energy,  $E_g$  is the band gap of the donor,  $\Delta E_c$  is the conduction band offset between the donor and acceptor, and the ( $E_g - \Delta E_c - 0.3$ ) term is an estimation of the maximum

open circuit voltage. For this formula, the smaller  $\Delta E_c$  means the greater value of PCE. Additionally, it requires a suitable  $E_g$ , because if the band gap of the donor is higher, the open circuit voltage will be better. However, the higher band gap will reduce the amount of photons that can be absorbed, which will reflect in the decrease of short circuit current. Here, the maximum PCE of InSe/Te vdW heterostructure is calculated to 13.39%, which is highlighted as red star in Figure 6. To show the uniqueness of InSe/Te vdW heterostructure, the PCE calculated by the same method for other 2D heterostructure solar cells are listed in Table 2. Therefore, we infer that the InSe/Te vdW heterostructure is a potential candidate for the high-efficiency solar cell application.



**Figure 6.** Simulated solar cell power conversion efficiency (PCE)  $\eta$  for InSe/Te heterostructure (marked as the red star).

**Table 2.** Calculated maximum power conversion efficiency (PCE) (%) of some recently reported 2D heterostructure solar cells.

System	РСЕ	References
InSe/Te	13.39	This work
GaTe/InS, GaTe/GaSe	11.52, 18.39	[15]
$Ti_2CO_2/Zr_2CO_2$	22.74	[14]
phosphorene/MoS <sub>2</sub>	16–18	[56]
PCBM/CBN	10-20	[6]

## 4. Conclusions

In summary, we established the vdW heterostructures by combining MX<sub>A</sub> (M = Al, Ga, In and  $X_A = S$ , Se, Te) and  $X_B$  ( $X_B = Se$ , Te) monolayers. Based on first-principles calculations, the stability and interlayer force of these heterostructures were demonstrated by the formation and binding energy. From screening, the InSe/Te vdW heterostructure shows type-II electronic band structure feature with a band gap of 0.88 eV, where the tellurene as absorber layer with a direct band gap about 1.14 eV could produce the photoexcited electron easily. In addition, tellurene and InSe monolayer respectively exhibit high absorption coefficient and low reflectivity. Furthermore, the maximum power conversion efficiency (PCE) of InSe/Te vdW heterostructure can reach up to 13.39%. Very recently, multilayer InSe/Te vdW heterostructure was experimentally observed and showed potential application in electronic and optoelectronic devices [57]. We believed that monolayer InSe/Te vdW heterostructure can be experimentally realized and show better performance. Our present research not only finds a novel type-II heterostructure for high-efficiency solar cell, but also further guides the design of more 2D vdW semiconductors for photovoltaic materials.

**Supplementary Materials:** The following are available online at https://www.mdpi.com/article/ 10.3390/ma14143768/s1, Figure S1: Projected band structures of (a) AIS, (b) AISe, (c) AITe, (d) GaS, (e) GaSe, (f) GaTe, (g) InS, (h) InSe, (i) InTe, (j) Se and (k) Te monolayers by HSE06 hybrid functional method. The red, brown, blue circles represent the projected specific gravity of M, X<sub>A</sub>, X<sub>B</sub> atoms, respectively. The first Brillouin zone with high-symmetry points are shown in the inset of (a). (l) The band edge alignments of these monolayers, Table S1: the lattice constants *a* (Å), the M-M, M-X<sub>A</sub> and X<sub>B</sub>-X<sub>B</sub> (M = AI, Ga, In, X<sub>A</sub> = S, Se, Te and X<sub>B</sub> = Se, Te) bond lengths  $L_{M-M}$  (Å),  $L_{M-XA}$  (Å) and  $L_{XB-XB}$ (Å), the PBE and HSE band gaps  $E_g^{PBE}$  (eV),  $E_g^{HSE}$  (eV) for the MX<sub>A</sub> and X<sub>B</sub> monolayers, Table S2: the energy differences  $\Delta E$  (meV) and interlayer distances *d* (Å) as well as the lattice constants *a* (Å) and bond lengths *L* (Å) of various configurations for AlX<sub>A</sub>/X<sub>B</sub> vdW heterostructures, Table S3: the energy differences  $\Delta E$  (meV) and interlayer distances *d* (Å) as well as the lattice constants *a* (Å) and bond lengths *L* (Å) of various configurations for GaX<sub>A</sub>/X<sub>B</sub> vdW heterostructures, Table S4: the energy differences  $\Delta E$  (meV) and interlayer distances *d* (Å) as well as the lattice constants *a* (Å) and bond lengths *L* (Å) of various configurations for GaX<sub>A</sub>/X<sub>B</sub> vdW heterostructures, Table S4: the energy differences  $\Delta E$  (meV) and interlayer distances *d* (Å) as well as the lattice constants *a* (Å) and bond lengths *L* (Å) of various configurations for GaX<sub>A</sub>/X<sub>B</sub> vdW heterostructures, Table S4: the energy differences  $\Delta E$  (meV) and interlayer distances *d* (Å) as well as the lattice constants *a* (Å) and bond lengths *L* (Å) of various configurations for InX<sub>A</sub>/X<sub>B</sub> vdW heterostructures.

**Author Contributions:** Conceptualization, R.L. and B.S.; methodology, Y.Z.; software, Y.Z. and B.S.; validation, R.X., Y.Z. and C.X.; formal analysis, R.L. and B.S.; investigation, Z.M., R.L.; resources, Y.Z. and B.S.; data curation, Z.M., R.L. and R.X.; writing—original draft preparation, Z.M. and R.L.; writing—review and editing, C.W. and B.S.; supervision, B.S.; project administration, B.S.; funding acquisition, C.W. and B.S. All authors have read and agreed to the published version of the manuscript.

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